

for 10/738,360

Refine Search

Search Results -

Terms	Documents
(resist or photoresist) and (fluorine or "nf.sub.3" or "cf.sub.4" or "c.sub.2f.sub.6" or "cf.sub.4") same plasma same (oxygen or "o.sub.2" or ozone or "o.sub.3") same ((low adj concentration) or percent)	122

Database:

US Pre-Grant Publication Full-Text Database

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IBM Technical Disclosure Bulletins

Search:

L2

Refine Search

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DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=ADJ

L2 (resist or photoresist) and (fluorine or "nf.sub.3" or "cf.sub.4" or "c.sub.2f.sub.6" or "cf.sub.4") same plasma same (oxygen or "o.sub.2" or ozone or "o.sub.3") same ((low adj concentration) or percent)

122

L2

L1 (fluorine or "nf.sub.3" or "cf.sub.4" or "c.sub.2f.sub.6" or "cf.sub.4") same plasma same (oxygen or "o.sub.2" or ozone or "o.sub.3") same ((low adj concentration) or percent)

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L1

END OF SEARCH HISTORY